



Creative Design Engineering, Inc. introduces its next generation ResMap **Four Point Probe** Resistivity Mapping System. The [ResMap 575-EFEM](#) offers the accuracy and cost-effectiveness of the standard ResMap linked with the automation and high productivity of an Equipment Front End Module (EFEM).



- High performance, ultraclean design
- Intelligent, flexible, stable wafer handling
- Multiple film capability with dual- and quad-head probes
- Meets all applicable SEMI standards
- Multiple metrology, cluster platform, multiple throughput
- Superior long term reliability
- Ease of configuration and integration ResMap or other vendor's system on a same platform



ResMap 168

ResMap 273

ResMap 178

ResMap 468

ResMap 168-Solar